C orrelated defects, m etal-insulator transition, and m agnetic order in ferrom agnetic sem iconductors

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The e ect of disorder on transport and m agnetization in ferrom agnetic III{V sem iconductors, in particular ($Ga_M n$)As, is studied theoretically. We show that Coulomb-induced correlations of the defect positions are crucial for the transport and m agnetic properties of these highly compensated m aterials. We employ M onte C arb simulations to obtain the correlated defect distributions. Exact diagonalization gives reasonable results for the spectrum of valence-band holes and the m etal-insulator transition only for correlated disorder. Finally, we show that the m ean-eld m agnetization also depends crucially on defect correlations.

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Introduction. Recently, there has been substantial interest in diluted ferrom agnetic III{V sem iconductors due to observations of relatively high Curie temperatures [1, 2, 3]. This makes these materials promising for applications as well as interesting from the physics point of view. They could allow the incorporation of ferrom agnetic elements into sem iconductor devices, and thus the integration of processing and m agnetic storage on a single chip. To be specic, we consider here manganese-doped GaAs. The properties of this material rely on the dual role played by the M n im purities: They carry a local spin due to their half-lled d-shell and dope the system with holes, which mediate a ferrom agnetic indirect exchange interaction between the spins. Furtherm ore, the materials are highly compensated presum ably due to antisite defects (As substituted for Ga) [4], which drives them towards a metal-insulator transition (MII). It is clearly in portant to understand the interplay between transport properties, m agnetic ordering, and the defect con guration. In this letter we show that correlated defects are required for a description consistent with experiments.

There is a growing body of theoretical work on (Ga,Mn)As [5]. Most approaches either start from the heavily doped regime [6, 7, 8, 9, 10, 11, 12] or from the weak-doping limit [13]. In the case of heavy doping [6, 7, 8, 9, 10, 11, 12] one considers valence-band holes moving in the disorder potential of the defects. For large hole concentration the Ferm i energy E_F lies deep in the valence band com pared to the Coulom b-potential uctuations and the latter are neglected. On the other hand, for light doping [13] the local in purity states overlap only weakly, forming an impurity band. This model is problem atic since for the typical doping range the im purity band would be much broader than the energy gap [14]. Both approaches have in comm on that the e ect of antisites on the disorder and correlations of defects are neglected.

The outline of the remainder of this paper is as follows. First, we discuss the conguration of Mn impurities and antisite defects with the help of Monte Carlo simulations and obtain the disorder potential and its spatial correlations. Then, we derive the spectrum and localization properties of holes in this potential and discuss the M II. Finally, we calculate the polarizations of M n and hole spins within a selfconsistent mean-eld theory.

D effect con gurations. In the theory of doped sem iconductors one often assume the dopants to be random by distributed [5, 15]. However, the present system is high by compensated. This leads to defects of either charge being present (relative to Ga, Mn impurities have charge

e while antisites carry + 2e) and to a low density of carriers, which only weakly screen the C oulom b interaction between the charged defects [15]. In the resulting C oulom b plasm a the defect positions are expected to be highly correlated. We study here the limiting case where the defects come into therm al equilibrium during grow th [16]. This is motivated by experiments [4] suggesting that defects di use rapidly at 250 C, which is a typical grow th and annealing tem perature for (G a, M n)A s grow n by m olecular beam epitaxy. The resulting con guration is assumed to be quenched at low tem peratures.

To nd typical defect con gurations close to equilibrium we perform M onte C arb simulations for the classical C oulomb system of M n in purities and antisites on the G a sublattice with the H am iltonian H = 1=2 _{i,j} q_iq_j=(r_{ij}) e^{r_{ij}=r_{scr}, where q_i are the defect charges, r_{ij} is their separation, and = 11. The screening length r_{scr} is obtained from nonlinear screening theory [15]. r_{scr} is much larger than the nearest-neighbor separation of G a sites for realistic parameters so that it hardly a ects the small-scale defect correlations relevant here. We employ the M etropolis algorithm at 250 C for system s of 20 20 conventional cubic unit cells with periodic boundary conditions, unless stated otherw ise.}

A typical result for M n concentration x = 0.05 and p = 0.3 holes per M n, as suggested by experiments [1], is shown in Fig. 1. The concentration of antisites is obtained from x and p under the assumption of charge neutrality. M ost of the defects have form ed clusters. This leads to screening of the disorder potential by the de-

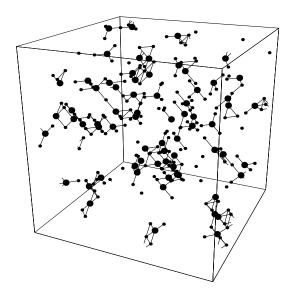


FIG. 1: Typical equilibrium con guration at 250 C for 5% M n doping and 0.3 holes per M n. O nly the defects are shown, large (sm all) circles denote antisite (M n) defects. Defects at nearest neighbor G a sites are connected by a bond. For clarity we show only 10 10 conventional unit cells.

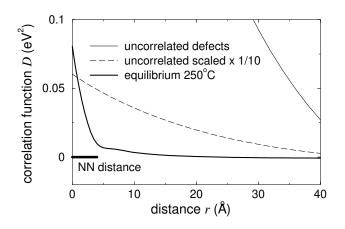


FIG. 2: Potential correlation function D (r) for 5% M n and 0.3 holes per M n, both for uncorrelated defects and for equilibrium at the growth tem perature. The nearest-neighbor G a site separation of 3.99A is also indicated.

fects, as can be seen from the potential correlation function D (r) hV (r) V (r⁰) $i_{jr} r^{0}_{j=r}$ hV i^2 plotted in F ig. 2 for x = 0.05 and p = 0.3. Note that V D (0) is the width of the distribution of V (r). For correlated defects, D (r) and thus V are strongly reduced and the C oulom b potential is screened on the much shorter length scale r_{ion} , which is of the order of the nearest-neighbor G a site separation [17]. (This ionic screening is only possible due to the presence of defects of either charge. T hus it does not take place, e.g., in ferrom agnetic II(V I sem iconductors since M n is isovalent in these m aterials.) Im portantly, however, V 0.284 eV is still not sm all

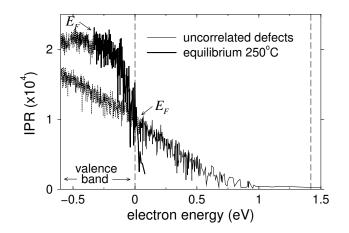


FIG.3: \mathbb{PR} as a function of energy at the valence-band edge for 5% M n and 0.3 holes per M n. The thin (heavy) solid line denotes empty states for uncorrelated (correlated) defects, the dotted lines denote occupied states.

com pared to the Fermi energy E_F j 0:329 eV.

Recent high resolution x-ray di raction [18] as well as resistivity and magnetization measurements [4] support the formation of small clusters. The more direct determ ination of the local structure around M n dopants by extended x-ray-absorption ne structure [19] does not give direct information on the abundance of speci c elements around the M n. However, the observed loss of order around M n is certainly consistent with cluster formation. Finally, we show in the following that experimental results for the band gap, transport, and the magnetization [1, 20] strongly support the clustering.

Hole states. To nd the spectrum and localization properties of valence-band holes moving in the disorder potential V (r), we start from the Ham iltonian H =

 $_{i}$ (h²=2m) r_i² + V (r_i), where we use the envelope function and parabolic-band approximations [21]. The calculations are done for spin-less holes, which is justified since the additional disorder introduced by the exchange interaction with the M n spins is much smaller than V.

The H am iltonian is solved by exact diagonalization in a plane-wave basis of $13^3 = 2197$ states [22], giving the energy spectrum and normalized eigenfunctions. The Ferm i energy E_F is obtained from the hole concentration px. We also obtain the inverse participation ratio IPR (n) = $1 = \frac{1}{r} j_n(r) f$ of the states n(r). The IPR allows to estimate the position of the mobility edge, since it is of the order of the volume for extended states but is essentially independent of system size for localized states. Figure 3 shows a comparison of the IPR as a function of energy for uncorrelated defects and for the equilibrium con guration obtained above, for 5% M n and 0.3 holes per M n. The valence-band edge is strongly smeared out by uncorrelated defects so that the energy gap is completely led, which is not observed experimen-

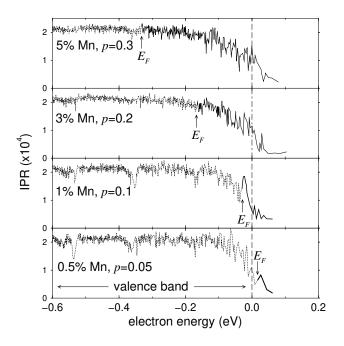


FIG.4: \mathbb{PR} as a function of energy at the valence-band edge for various M n dopings and hole concentrations p per M n taken from experiment [1, 23].

tally, whereas correlated defects only lead to a small tail in the gap. We have also studied the dependence of the IPR on system size L³ over the limited feasible range in L, nding that IPR (n) / L³ for the at part of the curve, signifying extended states, whereas the IPR is independent of L for states su ciently far in the tail, which are thus localized. Hence, the mobility edge lies on the slope of the curve. The states are much more localized for uncorrelated defects, due to the larger disorder potential, whereas for correlated defects the states close to $E_{\rm F}$ are clearly extended. Thus the spectrum and the localization properties agree with experiments [1] only for correlated defects.

In Fig. 4 we show the IPR as a function of energy for correlated defects at various M n dopings and hole concentrations. The hole concentration for given M n doping was chosen in accordance with experiments [1, 23]. The spectrum and the IPR change little with M n doping, since the potential screened by the defects on the length scale $r_{\rm ion}$ is much less a ected by a change of concentration than the bare C oulom b potential.

The dom inant e ect com es from the hole concentration. Our result for the scaling of the IPR suggests that for 5% and 3% M n the states at $E_{\rm F}$ are extended and we expect m etallic behavior. For 1% M n $E_{\rm F}$ is close to the m obility edge, while for 0.5% M n the states at $E_{\rm F}$ are localized. From this we estimate the M IT to take place at a M n concentration of the order of 1%. This result is in reasonable agreement with experiments [1]. For comparison, uncorrelated defects would lead to an M IT at

about 5% Mn, see Fig. 3.

M agnetization | Finally, we discuss the spontaneous magnetization and its dependence of the defect conguration. The exchange interaction between hole and M n spins is described by the Hamiltonian H = $_{i}(h^{2}=2m) r_{i}^{2} + V(r_{i}) J_{pd}_{i;l} s_{i} \$ ($r_{i} R_{1}$), where V (r) is the disorder potential obtained above, J_{pd} 45 eV A³ is the exchange integral [9, 24, 25], s_{i} and S_{1} are the hole and M n spin operators, respectively, and R₁ are the M n in purity positions. In second quantized form, the Hamiltonian reads

$$H = C_{n}^{Y} \circ C_{n}$$

$$T_{pd} = C_{n}^{Y} \circ C_{n}$$

$$T_{pd} = C_{n}^{Y} \circ C_{n} \circ C_{n}^{Y} \circ C_{n}^$$

where n are the eigenenergies obtained in the absence of exchange as discussed above, n (r) are the correspondis the vector of Paulim atriing eigenfunctions, and ces. The exchange interaction is decoupled at the meaneld level, introducing the averaged M n spin polarizations M 1 hS_bi and hole spin polarizations at the M n h $_{n \ m^{\circ} \circ c_{n}^{V}} c_{n}^{V} c_{n}^{V} (R_{1}) (\circ =2) _{n^{\circ}} (R_{1}) c_{n^{\circ}} \circ i.$ sites, m 1 W e do not perform a spatial average, i.e., the disorder is retained. The hole and M n sectors can now be diagonalized separately, M_{1} and m_{1} are calculated, and the procedure is iterated. This selfconsistent m ean-eld theory is sim ilar to the one employed by Berciu and Bhatt [13]. The main di erence is that we start from realistic hole states for the disorder potential.

Figure 5(a) shows the Mn and hole spin polarizations for x = 0.05 and p = 0.3. A lso shown are the polarizations obtained neglecting disorder by using plane waves for the hole states and the virtual crystal approxim ation (VCA) for the Mn spins [5, 7, 21]. We see that disorder strongly enhances T_c [13]. This increase is easily understood: T_c is determ ined by the indirect exchange interaction of nearest-neighbor M n pairs, which is inversely proportional to the separation [6, 7, 8]. W ithout disor $n_{Mn}^{1=3}$, where n_{Mn} is the der, the typical distance is r_{vca} density of M n in purites. For x = 0.05, r_{vca} 9:67A.On the other hand, with disorder the nearest-neighbor separation on the G a sublattice is $r_{dis} = 3.99 A$. Therefore, the indirect exchange, and thus T_c, is larger by a factor of order $r_{vca}=r_{dis}$ 2:4 in the disordered case.

For correlated defects the polarization curve looks m ore m ean-eld-like," in qualitative agreem ent with experiments [1, 10, 20]. This can be explained by the extended nature of the relevant hole states for correlated defects, which leads to a long-range indirect exchange interaction. Thus the elective eld seen by a M n spin is averaged over m any other M n spins and the spatial uctuations of this elective eld are small. On the other hand, for uncorrelated defects the holes are partly localized, the indirect exchange is of shorter range, and the

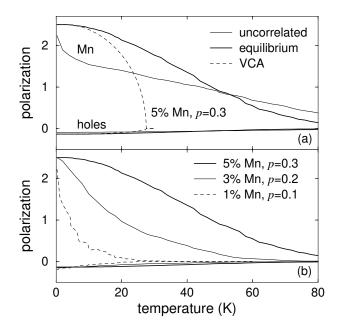


FIG.5: (a) M agnetization as a function oftem perature for 5% M n and 0.3 holesperM n, both for uncorrelated and correlated defects. The results denoted by \VCA " neglect disorder. (b) M agnetization for various M n and hole concentrations (with correlated defects).

uctuations are larger. We believe that this leads to the sm eared-outm agnetization curve. It is clearly important to study the e ect of uctuations on the magnetization. We expect uctuations to reduce T_c in particular for the uncorrelated case. Figure 5(b) shows that T_c is reduced for sm aller M n and hole concentrations and that the typical tem perature scale is approximately proportional to x, in accordance with experiments [1]. Note also that in all cases the holes are only partially polarized.

To conclude, we have obtained typical defect con gurations in (G a,M n)As and studied the e ect of the resulting disorder potential on the valence-band holes. The strong C oulom b interactions of charged defects leads to the form ation of defect clusters during grow th. The previously neglected antisite defects are crucial for this effect. W e have shown that such a correlated defect distribution is required to understand the hole spectrum, the m etal-insulator transition, and the shape of the m agnetization curves. Our results should also help to clarify why the properties of ferrom agnetic sem iconductors depend so strongly on details of the grow th process. | W e pro ted from discussions with P.J.Jensen, J.Konig, J. Schliem ann, and in particular M.E.Raikh, who em phasized to us the im portance of com pensation.

Note added. Recently, Y ang and M acD onald [26] have studied the e ect of the hole-hole interaction, assuming a random distribution of M n dopants and antisites. E lectronic address: tim m @ physik.fu-berlin.de

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